

Search Results -

Search Results -				
Term	Documents			
PLASMA.DWPI,TDBD,EPAB,JPAB.	141363			
PLASMAS.DWPI,TDBD,EPAB,JPAB.	951			
PLASMAS.DWPI, IDDD, EDAR IPAR	79160			
MICROWAVE.DWPI,TDBD,EPAB,JPAB	10873			
MICROWAVES.DWPI,TDBD,EPAB,JPAB.	51424			
RF.DWPI,TDBD,EPAB,JPAB.	121			
RFS.DWPI,TDBD,EPAB,JPAB	193477			
RADIO.DWPI,TDBD,EPAB,JPAB				
RADIOS.DWPI,TDBD,EPAB,JPAB	1933			
FREQUENCY.DWPI,TDBD,EPAB,JPAB.	725139			
FREQUENCIES DWPI, TDBD, EPAB, JPAB.	8306			
(PLASMA SAME (MICROWAVE AND (ADVANTAGE OR BENEFIT OR PREFER OR PREFERRED)) SAME (RF OR (RADIO FREQUENCY))). JPAB, EPAB, DWPI, TDBD.	1			

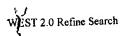
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BM Technical Disclosure Bulletins

Refine Search: plasma same (microwave and (advantage or benefit or prefer or preferred)) same Clear (RF or (radio frequency))
Search History

Today's Date: 5/8/2001



DB Name	Query	Hit Count	Set Name
JPAB,EPAB,DWPI,TDBD	plasma same (microwave and (advantage or benefit or prefer or preferred)) same (RF or (radio frequency))	18	<u>L15</u>
USPT,PGPB	plasma same (microwave and (advantage or benefit or prefer or preferred)) same (RF or (radio frequency))	237	<u>L14</u>
JPAB,EPAB,DWPI,TDBD	(diamond near2 like near2 carbon near2 film) and plasma and (microwave and (advantage or benefit or prefer or preferred))	21	<u>L13</u>
USPT,PGPB	(diamond near2 like near2 carbon near2 film) and plasma and (microwave same (advantage or benefit or prefer or preferred)) and (magnetic near3 record\$4)	1	<u>L12</u>
USPT,PGPB	(diamond near2 like near2 carbon near2 film) same plasma same microwave same (advantage or benefit or prefer or preferred) same (magnetic near3 record\$4)	0	<u>L11</u>
JPAB,EPAB,DWPI,TDBD	substrate and plasma and ((restricted or limited) near3 (plasma or discharge) near3 (zone or region))	13	<u>L10</u>
USPT,PGPB	substrate same plasma same ((restricted or limited) near3 (plasma or discharge) near3 (zone or region))	28	<u>L9</u>
USPT,PGPB	substrate same plasma same ((restricted or limited) near3 (plasma or discharge) near3 zone)	2	<u>L8</u>
USPT,PGPB	substrate same plasma same ((restricted or limited) near5 (plasma or discharge))	404	<u>L7</u>
JPAB,EPAB,DWPI,TDBD	((metal or conducting) near5 substrate) and plasma		<u>L6</u>
JPAB,EPAB,DWPI,TDBD	((metal or conducting) near5 substrate) same plasm same (hollow cathode)	a 6	<u>L5</u>
USPT,PGPB	((metal or conducting) near5 substrate) same plasm same (hollow cathode)	12	<u>L4</u>
USPT,PGPB	(((118/730)!.ICLS.)) and (roll or roller or winder of (band near2 (shaped or like)) or (hollow cathode); and (plasma same (CVD or (vapor deposition)))) 24	<u>L3</u>
USPT,PGPB	((((118/723E)!.ICLS.)) and (roll or roller or window or (band near2 (shaped or like)) or (hollow cathode)) and (plasma same (CVD or (vapor deposition)))	er 47	<u>L.2</u>
USPT,PGPB	((118/723MW)!.ICLS.) and (roll or roller or winder or (band near2 (shaped or like)) or (hollow cathode)) and (plasma same (CVD or (vapor deposition)))	v 28	<u>L1</u> .